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Docket No.: M4065.0319/P319-A
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Husam N. Al-Shareef, et al.

Application No.: 09/912,558

Group Art Unit: 2813

Confirmation No.: 5990

Filed: July 26, 2001

Examiner: E. Kielin

For: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN
INSULATING FILM USING A WET
RAPID THERMAL OXIDATION PROCESS

AMENDMENT AND RESPONSE TO RESTRICTION AND ELECTION OF
SPECIES REQUIREMENT

Commissioner for Patents
Washington, DC 20231

Dear Sir:

In response to the restriction/election requirement set forth in the last Office Action mailed January 2, 2002, Applicants elect the invention of Group I and the species Ia covered by claims 13-17 for continued examination, with traverse.

Please amend the above-identified patent application as follows:

IN THE CLAIMS:

Please rewrite claims 13 and 18 as shown in the Replacement Claims:

Please add the following new claims:

41. (new) A method of fabricating a semiconductor device, the method